

F-8509

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INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)				Applicant: Guenter HOLLEMAN, et al.		Filing Date:	
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U.S. PATENT DOCUMENTS							
Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
DAF		US- 5,631,769	5/20/1997	Wheatley			
FOREIGN PATENT DOCUMENTS							
		Document Number	Date	Country	Class	Subclass	Translation
							Yes No
DAF		DE- 100 43 269	4/4/2002	DE			Y*
		DE- 100 63 976	7/4/2002	DE			Y*
		EP- 0 609 978	8/10/1994	EP			N
DAF		WO- WO 96/16484	5/30/1996	WO			N
<p>TRANSLATION KEY: * English Abstract. ^F Concise statement of relevance provided in foreign search report. ^C Concise statement of relevance provided in specification. ^S Concise statement of relevance provided in IDS. ^P Relevant portion of reference translated. ^O English abstract only - copy of reference in pct search.</p>							
OTHER INFORMATION DISCLOSURE CITATIONS (Including Author, Title, Date, Pertinent Pages, Etc.)							
DAF		1/15/1998 Cascaded TeO2 acousto-optic devices for high efficiency multifrequency modulation, Kastelik J. C. et al. Journal of Applied Physics, American Institute of Physics, Volume 83 Pages 674-678					
		5/31/2002 Femtosecond technology for precision manufacturing: Fundamental and technical aspects, Friedrich DAUSINGER, Proceedings of the International Congress of Laser Advanced Materials Processing (LAMP), Pages 1-8					
		2001 High power thin disk Yb: YAG regenerative amplifier, Daniel Mueller, Steffen Erhard and Adolf Giesen, Advanced Solid-State Lasers, OSA TOPS Vol. 50 Pages 319 - 327					
DAF		1999 Solid-State Laser Engineering W. Koechner Springer Series in Optical Science, Springer Berlin, Fifth Edition Pages 578-581					
EXAMINER <i>[Signature]</i>				DATE CONSIDERED 8/07			
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